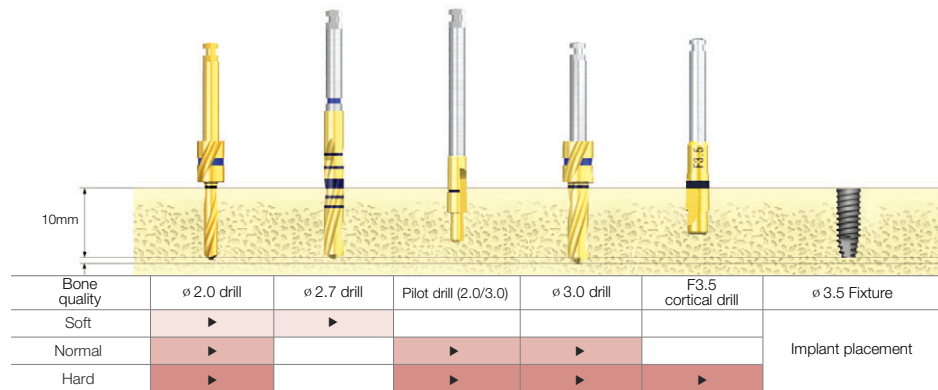


Drill Sequence for TSII Fixture

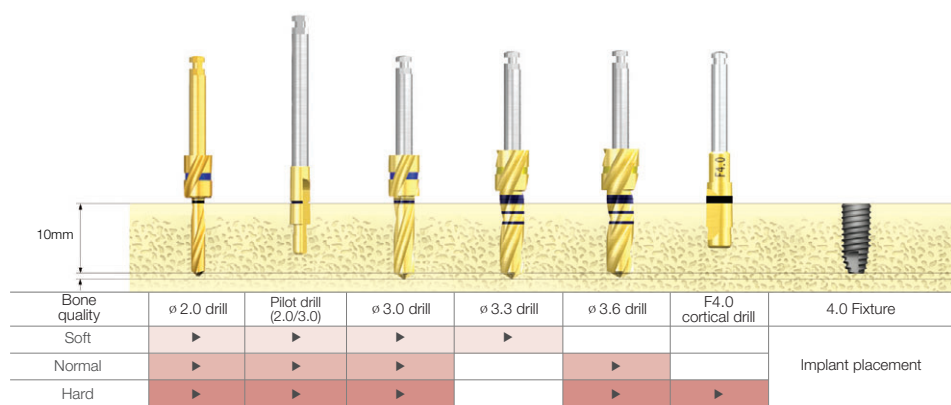
※ **GS KIT, Hanaro KIT User**

- It can be recommended implant placement 1mm deeply at normal & hard bone / -It can be recommended implant placement bone level at soft bone
- Limited insertion torque : 40Ncm

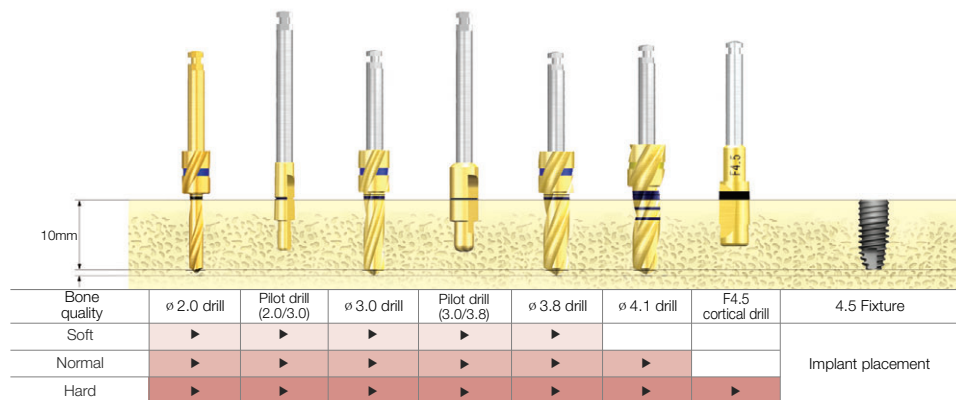
■ **ø 3.5mm Fixture (Length :10mm)**



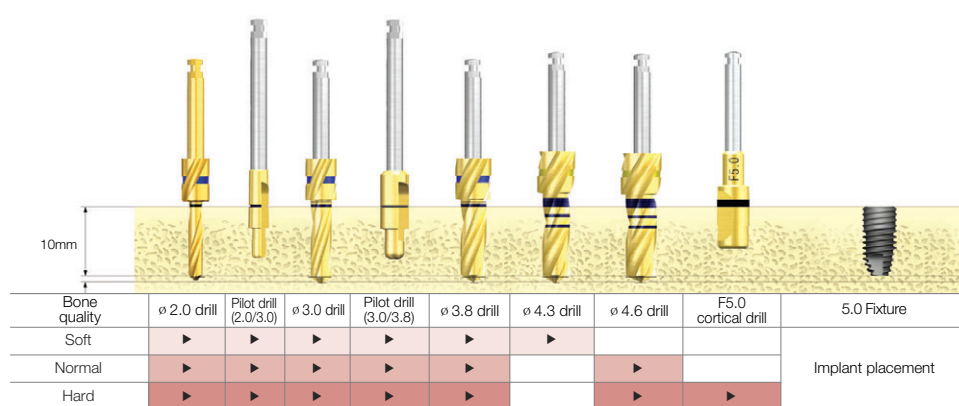
■ **ø 4.0mm Fixture (Length :10mm)**



■ **ø 4.5mm Fixture (Length :10mm)**



■ **ø 5.0mm Fixture (Length :10mm)**



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Busan, Korea. Zip_ 611-804
tel_ 82 51 850 2500
fax_ 82 51 861 4693

Edition 02 / 2012

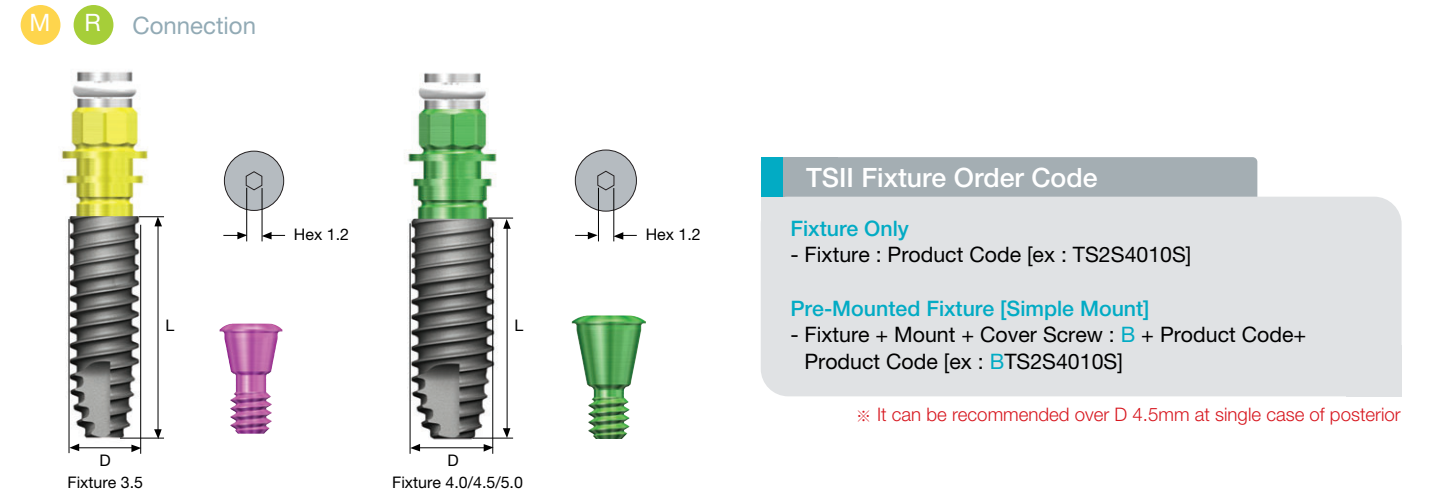
TSII Implant System Catalog & Manual

TSII implant reduces the bone healing time and has a optimal body design.

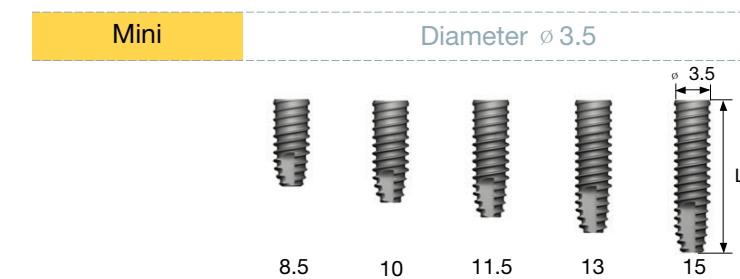
- Implantation performance
- Optimized design for SA surface
- Easy surgical protocol
- Increase initial stability and insertion feeling
- Powerful self threading

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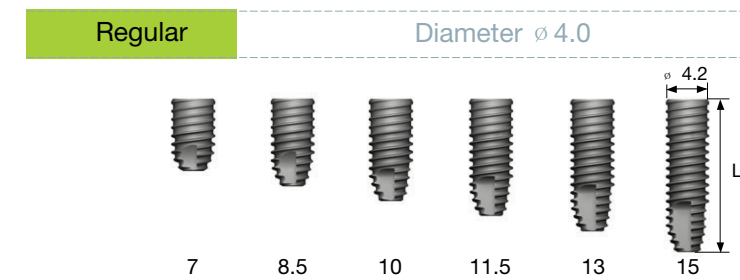
TSII Fixture Line Up



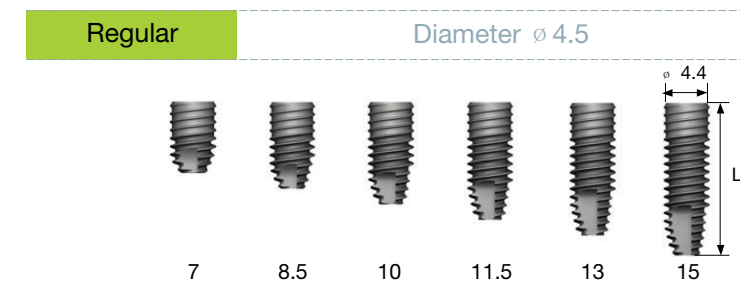
Feature of Osstym SA surface - equivalent level of morphology and roughness with 'S' manufacturer .
45% increase in surface area VS RBM



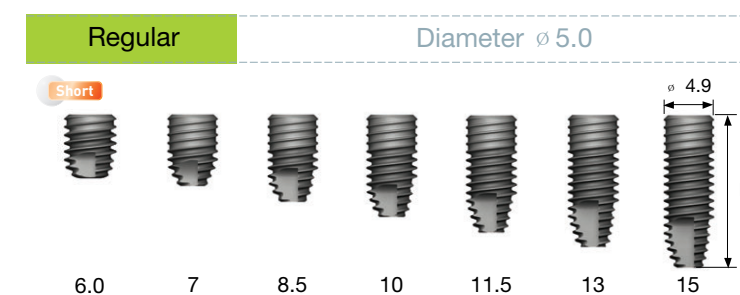
Connection	Mini
L \ D	ø 3.5
7	-
8.5	TS2M3508S
10	TS2M3510S
11.5	TS2M3511S
13	TS2M3513S
15	TS2M3515S



Connection		Regular
L	D	ø 4.0
7		TS2S4007S
8.5		TS2S4008S
10		TS2S4010S
11.5		TS2S4011S
13		TS2S4013S
15		TS2S4015S



Connection		Regular
L	D	ø 4.5
7		TS2S4507S
8.5		TS2S4508S
10		TS2S4510S
11.5		TS2S4511S
13		TS2S4513S
15		TS2S4515S



Connection		Regular
L \ D		ø 5.0
6		TS2S5006S
7		TS2S5007S
8.5		TS2S5008S
10		TS2S5010S
11.5		TS2S5011S
13		TS2S5013S
15		TS2S5015S

- SA : Sand blasted with alumina and Acid etched surface
 - Optimal morphology : combine crater and micro-pit
 - Optimal surface roughness : Ra 2.5~3.0 μ m
 - Early cell response : 20% higher than RBM
 - Early bone healing : 20% higher than RBM
 - Load 6~8 weeks after implantation